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Thin Films: Growth and Characterization

Guest Editors:

Dr. Victor Leca

Department Extreme Light
Infrastructure-Nuclear Physics
(ELI-NP), Horia Hulubei National
Institute for R&D in Physics and
Nuclear Engineering, Bucharest,
Romania

Prof. Dr. Maria Dinescu

INFLPR—National Institute for
Laser, Plasma and Radiation
Physics, Magurele, Romania

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Message from the Guest Editors

Dear colleagues,

This Special Issue will bring together papers with topics in the field of thin films, more particularly on chemical and physical fabrication methods and technologies for thin film growth and their characterization. Aspects such as surface modifications of substrates used as templates will be also considered. Correlation between microstructural, morphological, and electrical properties will be emphasized based on techniques such as X-ray and electron diffraction, transmission electron microscopy, atomic force microscopy, X-ray, electron or positron spectroscopy, and electrical transport property measurements. A large spectrum of materials and structures are considered, such as semiconductors, superconductors, materials for spintronics, nitrides, ZnO, multiferroics, ferroelectrics, plasmonic materials, transparent conductors, superlattices, nanocrystals, polymers, carbon-based materials, and others. Companies are encouraged to present new products that can be used for any of the above topics.





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Editor-in-Chief

Prof. Dr. Maryam Tabrizian

1. Department of Biomedical Engineering, Faculty of Medicine and Health Sciences, McGill University, Montreal, QC H3A 2B6, Canada

2. Faculty of Dentistry and Oral Health Sciences, McGill University, 3640 Rue University, Montreal, QC H3A 0C7, Canada

Message from the Editor-in-Chief

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Contact Us

Materials Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland

Tel: +41 61 683 77 34
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